



# High-Efficiency Cleaning Agent SPO-717

Customer A  
Performance Data:  
+0.062% Eff compared  
to baseline

Item	Uoc	Isc	Rs	Rsh	FF	Eta	Irev2
Baseline	0	0	0	0	0	0	0
SunFonergy	0.0015	0.014	0.05	101	-0.05	0.062	-0.017

Customer B  
Performance Data:  
+0.08% Eff compared  
to baseline

Item	Uoc	Isc	Rs	Rsh	FF	Eta	Pmpp
Baseline	0	0	0	0	0	0	0
SunFonergy	1.5	0.002	- 0.04	34	0.09	0.08	0.019



Increases efficiency;  
SunFonergy's SPO thoroughly remove the residues after texturing and etching, and disperse residues away from wafer surface, than increases cell efficiency.



High compatibility;  
No change to the present equipment and production process.